

**Amendments to the Claims:**

The following listing of claims will replace all prior versions, and listings, of claims in the application:

1. (Currently Amended) A plasma generating electrode comprising at least a pair of electrodes disposed opposite to each other and generating plasma upon application of voltage between the pair of electrodes,

at least one of the pair of electrodes including a ~~plate-like ceramic body~~ plate having two major surfaces as a dielectric and a conductive film disposed inside the ceramic plate sandwiched between the two major surfaces and having a plurality of through-holes formed through the conductive film in its thickness direction, the through-holes having a cross-sectional shape including an arc shape along a plane perpendicular to the thickness ~~direction~~ direction,

wherein a cross-sectional area of the through-holes have a diameter of 1 to 10 mm.

2. (Currently Amended) The plasma generating electrode according to claim 1, wherein the through-holes have a circular cross-sectional shape along a the plane perpendicular to the thickness direction.

3. (Previously Presented) The plasma generating electrode according to claim 1, wherein the through-holes are regularly arranged in the conductive film.

4. (Currently Amended) The plasma generating electrode according to claim 1, wherein the conductive film is disposed inside the ceramic plate ~~formed body~~ by screen printing, calender rolling, spraying, chemical vapor deposition, or physical vapor deposition.

5. (Canceled)

6. (Previously Presented) The plasma generating electrode according to claim 1, wherein a center-to-center distance between the adjacent through-holes is 1.5 to 20 mm.

7. (Previously Presented) The plasma generating electrode according to claim 1, wherein the conductive film includes at least one metal selected from the group consisting of tungsten, molybdenum, manganese, chromium, titanium, zirconium, nickel, iron, silver, copper, platinum, and palladium as a major component.

8. (Previously Presented) A plasma generation device comprising the plasma generating electrode according to claim 1.

9. (Original) An exhaust gas purifying device comprising the plasma generation device according to claim 8 and a catalyst, the plasma generation device and the catalyst being disposed inside an exhaust system of an internal combustion engine.